

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: KIM, Ha Zoong Conf.: *#5/10e
Amndt
a*
Appl. No.: New Group: *11/7/01
1/8*
Filed: March 29, 2001 Examiner:
For: SEMICONDUCTOR DEVICE AND METHOD FOR
MANUFACTURING THE SAME

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, DC 20231

March 29, 2001

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application.

AMENDMENTS

IN THE CLAIMS:

Please amend the claims as follows:

D1
6. (Amended) The method of claim 5, further comprising forming a mask on the semiconductor substrate such that the deep well areas are formed in the chip formation areas and not in the scribe lanes.

A
7. (Amended) The semiconductor device of claim 5, wherein,

*bulk
B2*